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PATENT NUMBER and ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM	FILING DATE	CLASS	SUBCLASS	GAU	EXAMINER
10054532	01/22/2002	430		1752	CLARKE

****APPLICANTS:** Lee Geun; Jung Jae; Shin Ki;

BEST AVAILABLE COPY *yet*

****CONTINUING DATA VERIFIED:**

NONE yet

**** FOREIGN APPLICATIONS VERIFIED:**

REPUBLIC OF KOREA 2001-38118 06/29/2001 *yes*

PG-PUB	DO NOT PUBLISH <input type="checkbox"/>	RESCIND <input type="checkbox"/>
Foreign priority claimed	<input checked="" type="checkbox"/> yes <input type="checkbox"/> no	ATTORNEY DOCKET NO
35 USC 119 conditions met	<input checked="" type="checkbox"/> yes <input type="checkbox"/> no	30205/38083
Verified and Acknowledged Examiners's initials <i>[initials]</i>		

TITLE : Photoresist monomers, polymers thereof and photoresist compositions containing the same

U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for O.G.
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drwg.	Figs. Drwg. Print Fig.
		Application Examiner	
<input type="checkbox"/> TERMINAL DISCLAIMER		PREPARED FOR ISSUE	
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